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HORIBA Semiconductor features the CS-700 Advanced Concentration Monitor for Complex Chemistries at SEMICON West 2017

SUNNYVALE, CA June 28th, 2017 – HORIBA Semiconductor, global leader in Wet Process Monitoring, features its CS-700 for simultaneous monitoring of multi-constituent chemical baths used in critical wet processes at SEMICON West 2017 in San Francisco, CA.

Based on HORIBA's industry standard CS platform, the CS-700's advanced spectroscopic optical design enables multi-constituent monitoring of wet process chemistries. The new design enables simultaneous monitoring of an unprecedented eight bath constituents.

"The CS-700 represents a great advancement in the monitoring of process chemistries. By leveraging a proven design, we have been able to create a monitor that gives users far greater versatility in process monitoring that enables next generation processes", said Mark Mahoney, Business Development Manager for Wet Products at HORIBA Semiconductor.

HORIBA technologies for wet process monitoring are used globally for critical process monitoring and control and the CS-700 represents the latest in applications-driven technology development that supports the Semiconductor Industry.

HORIBA Semiconductor, part of HORIBA INSTRUMENTS, INC., headquartered in the United States, provides an extensive array of instruments and solutions for applications across a broad range of Semiconductor processes. HORIBA Semiconductor is a world leader in the measurement and control of critical process chemistries. Our instruments are found in equipment and facilities worldwide and HORIBA is a recognized technology leader in the Semiconductor industry.

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